



9/A and B (modified PTO/SB/08)

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

APPLICATION NO.: 10/021,740	ATTY. DOCKET NO.: M0925.70108US00
FILING DATE: October 22, 2001	CONFIRMATION NO.: 1110
APPLICANT: Yet-Ming Chiang et al.	
GROUP ART UNIT: 445 1795	EXAMINER: J.S. Maples

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* a copy of this reference is not provided as it was previously cited by or submitted to the office in a prior application, Serial No. __, filed __, and relied upon for an earlier filing date under 35 U.S.C. 120 (continuation, continuation-in-part, and divisional applications).

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